



US 20200185652A1

(19) **United States**

(12) **Patent Application Publication**
SUN

(10) **Pub. No.: US 2020/0185652 A1**

(43) **Pub. Date: Jun. 11, 2020**

(54) **ORGANIC LIGHT-EMITTING DIODE
DISPLAY PANEL, METHOD FOR
PREPARING THE SAME, AND DISPLAY
DEVICE**

(71) Applicant: **BOE Technology Group Co., Ltd.**,
Beijing (CN)

(72) Inventor: **Haiyan SUN**, Beijing (CN)

(21) Appl. No.: **16/516,894**

(22) Filed: **Jul. 19, 2019**

(30) **Foreign Application Priority Data**

Dec. 10, 2018 (CN) 201811503645.1

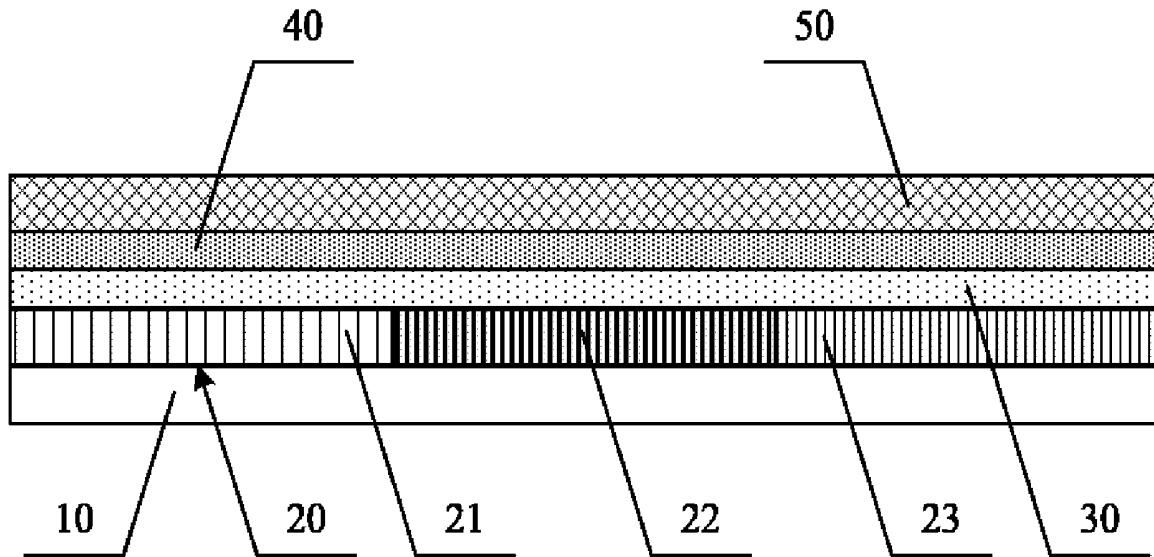
Publication Classification

(51) **Int. Cl.**
H01L 51/52 (2006.01)
H01L 51/56 (2006.01)

(52) **U.S. Cl.**
CPC *H01L 51/5271* (2013.01); *H01L 51/5275* (2013.01); *H01L 27/3213* (2013.01); *H01L 51/56* (2013.01); *H01L 51/5253* (2013.01)

(57) **ABSTRACT**

The present disclosure provides an organic light-emitting diode display panel, a method for preparing the same, and a display device. The organic light-emitting diode display panel includes a substrate, a light-emitting structure layer arranged on the substrate, and a light modulation layer arranged on a light exiting path of the light-emitting structure layer and configured to adjust a direction of an emergent light beam.



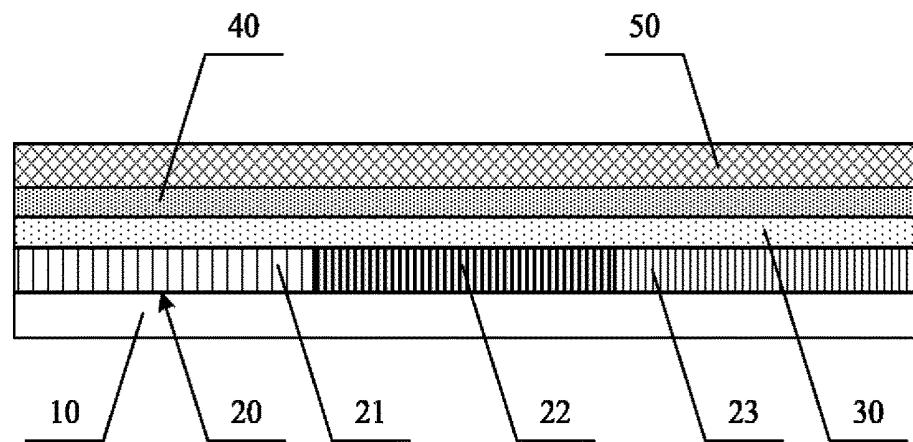


Fig. 1

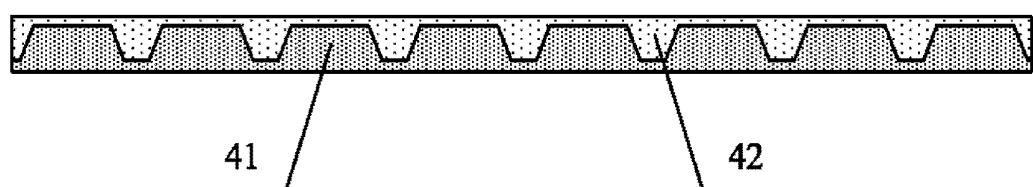


Fig. 2

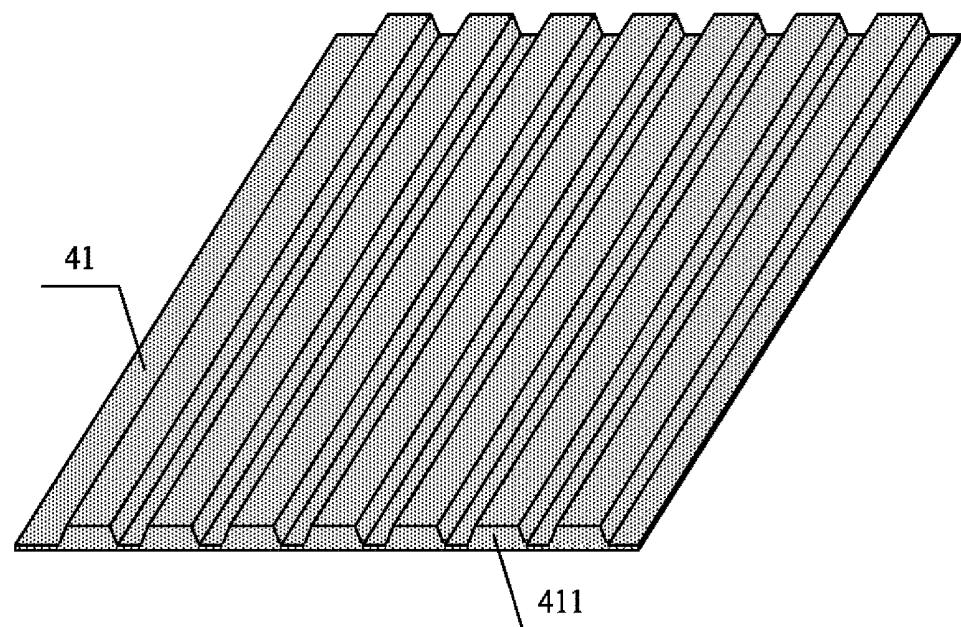


Fig. 3

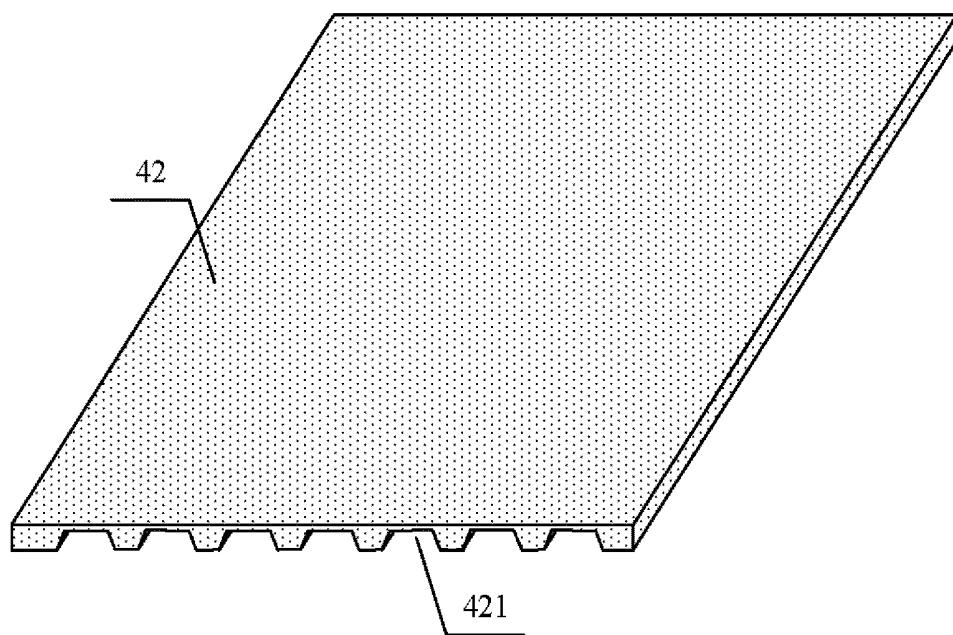


Fig. 4

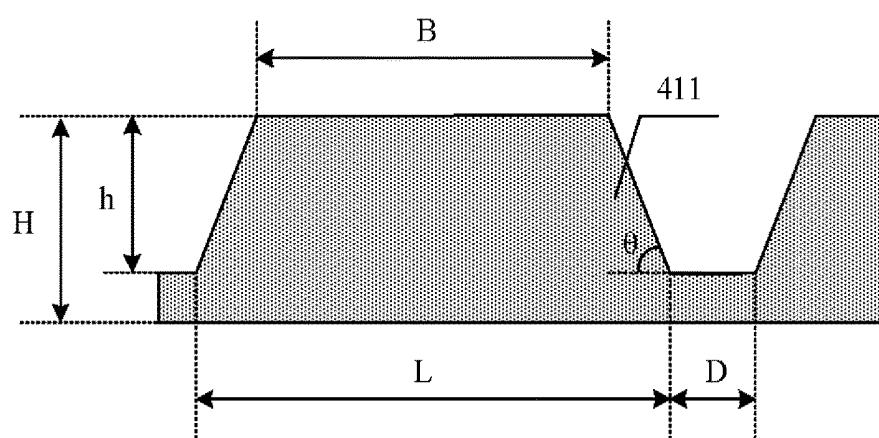


Fig. 5

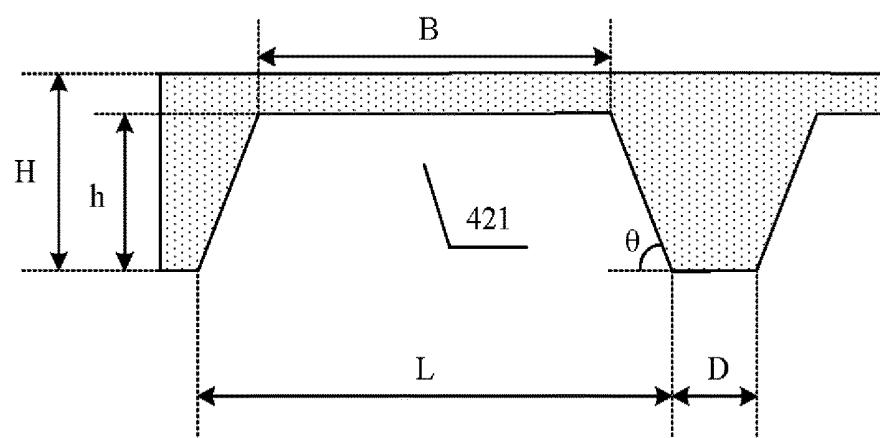


Fig. 6

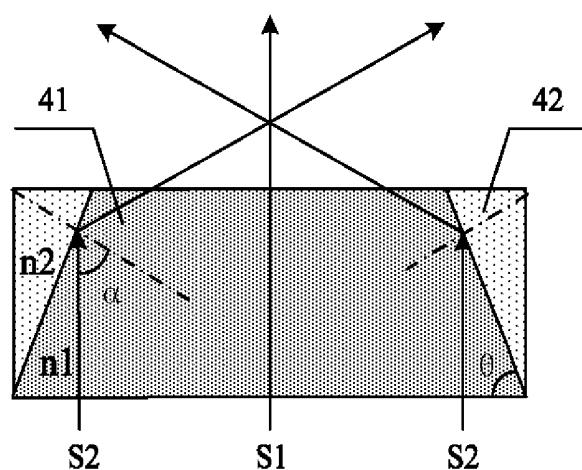


Fig. 7

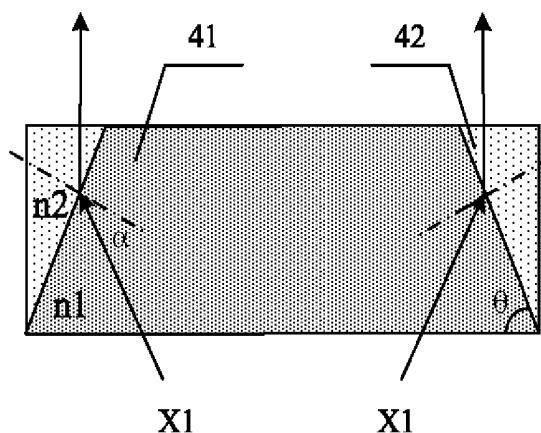


Fig. 8

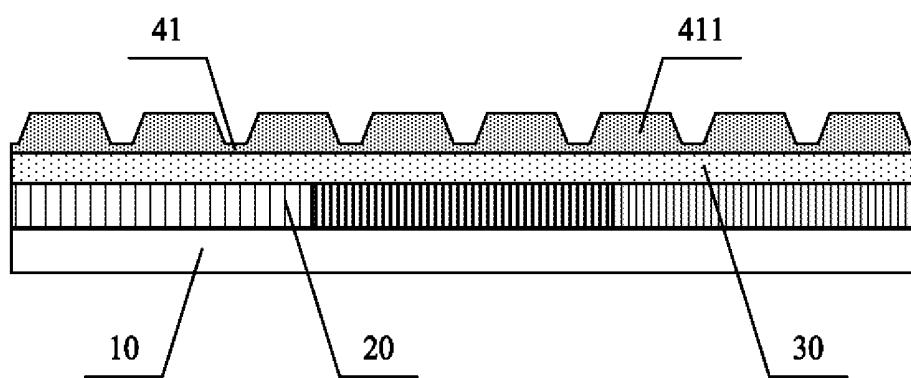


Fig. 9

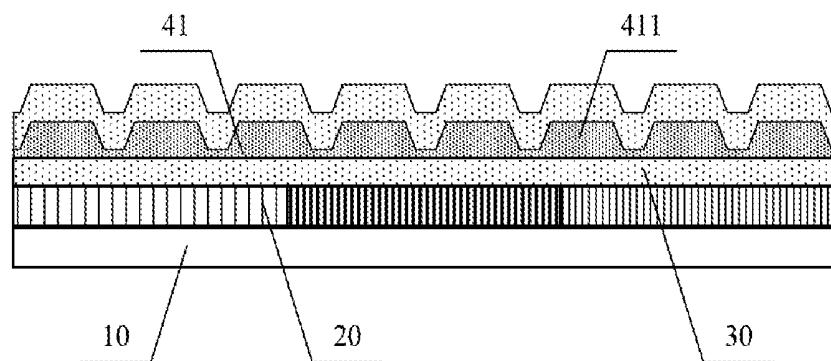


Fig. 10

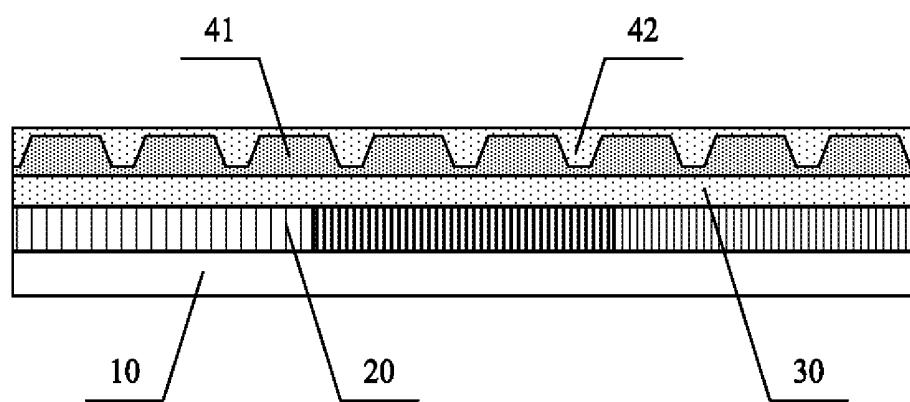


Fig. 11

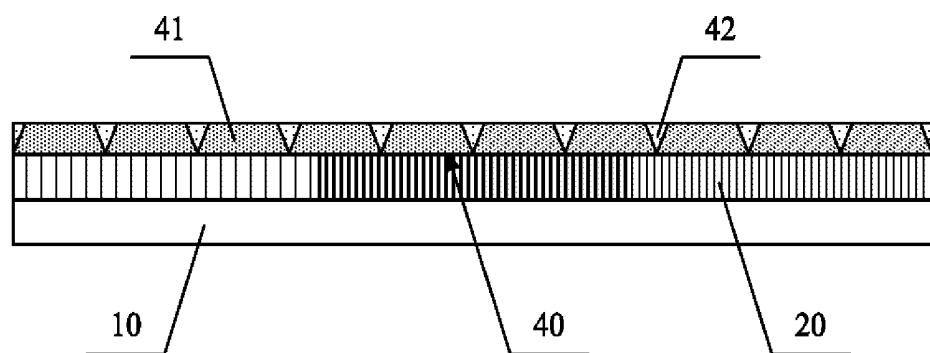


Fig. 12

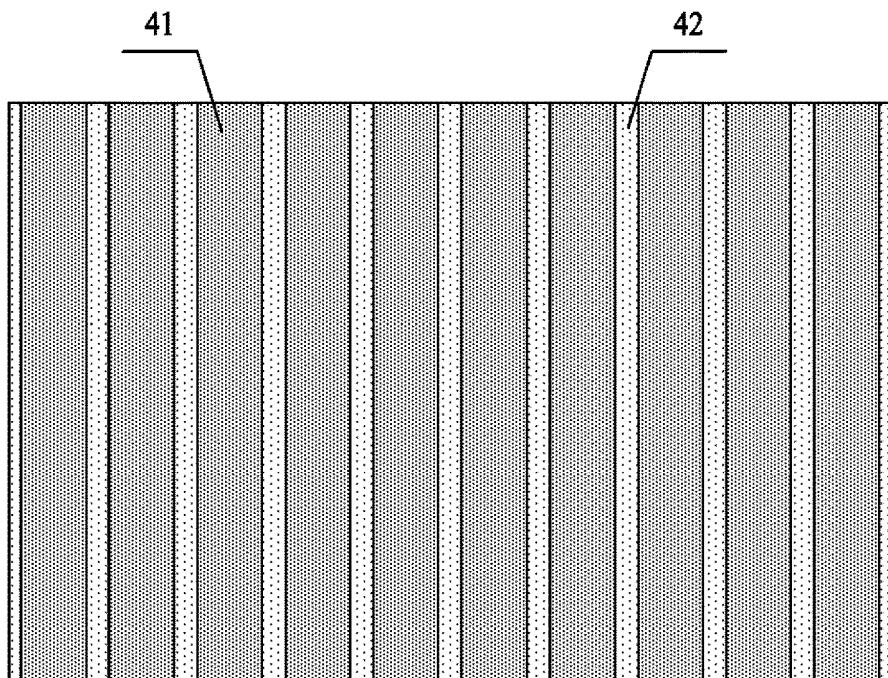


Fig. 13

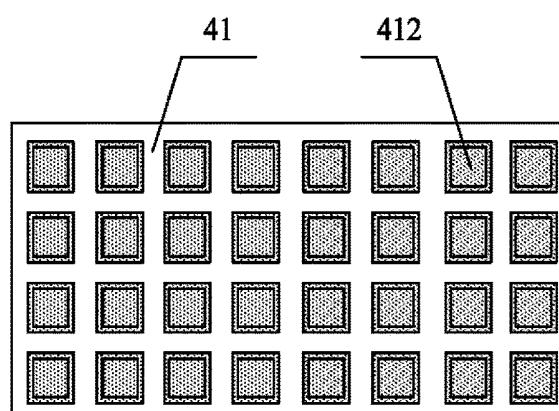


Fig. 14

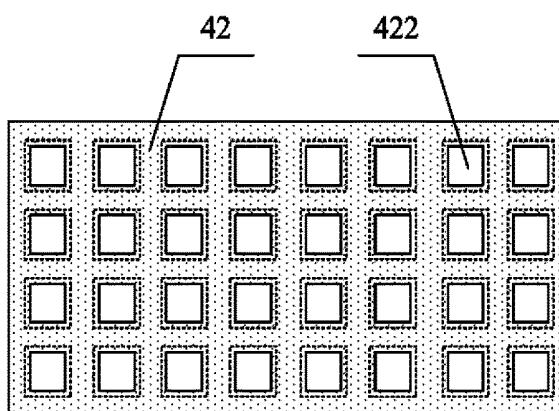


Fig. 15

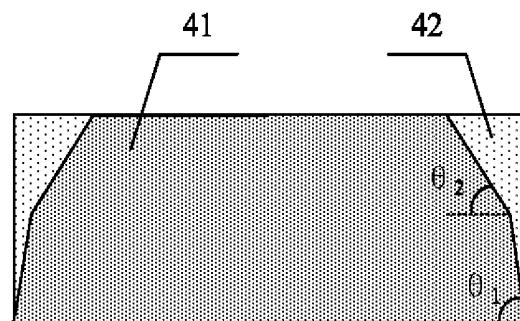


Fig. 16a

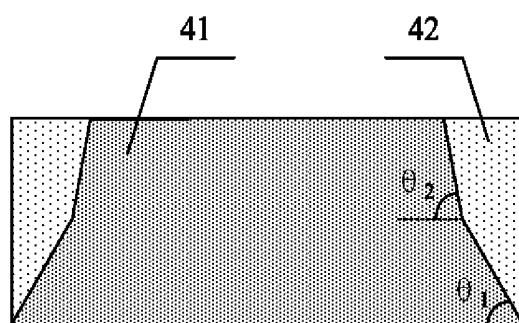


Fig. 16b

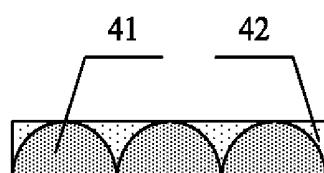


Fig. 16c

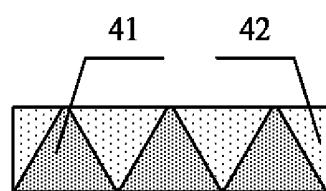


Fig. 16d

ORGANIC LIGHT-EMITTING DIODE DISPLAY PANEL, METHOD FOR PREPARING THE SAME, AND DISPLAY DEVICE

CROSS-REFERENCE TO RELATED APPLICATION

[0001] This application claims a priority to Chinese Patent Application No. 201811503645.1 filed on Dec. 10, 2018, the disclosures of which are incorporated in their entirety by reference herein.

TECHNICAL FIELD

[0002] The present disclosure relates to the field of display technology, in particular to an organic light-emitting diode display panel and a method for preparing the same, and a display device including the display panel.

BACKGROUND

[0003] The organic light-emitting diode (OLED) display panel is an active light-emitting display device, which has the advantages of self-illumination, wide viewing angle, high contrast, full color display, light weight, thin thickness, low power consumption, high reaction speed, etc., and which can achieve flexible display, and is the most promising display device.

[0004] The OLED display panel can be classified into a bottom emitting OLED and a top emitting OLED according to the position of the light emitting. Due to the low aperture ratio of the bottom emitting OLED, the current OLED display panel is usually of the top emitting OLED structure.

[0005] The main structure of the light-emitting unit in the OLED display panel includes a first electrode, a second electrode, and an organic electroluminescent structure layer arranged between the first electrode and the second electrode. In order to form a microcavity effect, generally, the first electrode is a total reflection electrode, and the second electrode is a transmissive electrode or a transflective electrode. The microcavity effect is capable of producing strong multi-beam interference, which has the effect of selecting, narrowing and strengthening the light source, so that the beam of front viewing angle is enhanced and the chromaticity is purified. However, the actual use shows that the microcavity effect has a problem of characteristic deviation of viewing angle. The characteristic deviation of viewing angle indicates that the brightness and chromaticity of the emergent light beam gradually decrease as the viewing angle increases, in which the brightness and chromaticity of the front viewing angle are the highest, and the brightness and chromaticity of the large viewing angle are low.

[0006] Therefore, how to solve the problem of characteristic deviation of viewing angle in the related technology is a technical problem to be solved in the field.

SUMMARY

[0007] The technical problem to be solved by the present disclosure is to provide an OLED display panel, a method for preparing the same, and a display device including the OLED display panel, to solve the problem of characteristic deviation of viewing angle in the related art.

[0008] In order to solve the above problem, an embodiment of the present disclosure provides an organic light-emitting diode display panel, including a substrate, a light-

emitting structure layer arranged on the substrate, and a light modulation layer arranged on a light exiting path of the light-emitting structure layer and configured to adjust a direction of an emergent light beam.

[0009] In an example, the light modulation layer is configured to totally reflect a part of a front viewing-angle emergent light beam from the light-emitting structure layer to change it into a large viewing-angle emergent light beam, and to refract a part of a large viewing-angle emergent light beam from the light-emitting structure layer to change it into a front viewing-angle emergent light beam, so as to redistribute the front viewing-angle emergent light beam and the large viewing-angle emergent light beam, in which a viewing angle is an angle between a normal direction of a display plane and a line of sight, the front viewing-angle emergent light beam is an emergent light beam having a viewing-angle in the range of 0° to 15°, and the large viewing-angle emergent light beam is an emergent light beam having a viewing-angle greater than 40°.

[0010] In an example, the light modulation layer is located on a side of the light-emitting structure layer away from the substrate.

[0011] In an example, the OLED display panel further includes: a protective layer arranged on a side of the light-emitting structure layer away from the substrate which is also a side of the light modulation layer proximate to the substrate; and a packaging layer arranged on a side of the light-emitting structure layer away from the substrate.

[0012] In an example, the light modulation layer includes a first structural layer and a second structural layer which are stacked, with the first structural layer having a first refractive index, and the second structural layer having a second refractive index less than the first refractive index.

[0013] In an example, a plurality of strip protrusions is provided on a surface of the first structural layer facing the second structural layer; and a plurality of strip grooves is provided on a surface of the second structural layer facing the first structural layer, with the plurality of strip grooves on the second structural layer being attached to the plurality of strip protrusions on the first structural layer, and with each pair of the plurality of strip protrusions and the plurality of strip grooves having the same shape of trapezoid in a cross section perpendicular to the substrate and parallel to a length direction of the substrate.

[0014] In an example, a plurality of block protrusions is provided on a surface of the first structural layer facing the second structural layer; and a plurality of block grooves is provided on a surface of the second structural layer facing the first structural layer, with the plurality of block grooves on the second structural layer being attached to the plurality of block protrusions on the first structural layer, and with each pair of the plurality of block protrusions and the plurality of block grooves having the same shape of trapezoid in a cross section perpendicular to the substrate and parallel to a length direction of the substrate.

[0015] In an example, an angle θ between a lateral side and a lower side of the trapezoid is greater than or equal to 55° and less than or equal to 90°.

[0016] In an example, a height of the trapezoid is equal to a thickness of the first structural layer or the second structural layer, and a pitch between the plurality of strip protrusions or the plurality of block protrusions is zero.

[0017] In an example, a lateral side of the trapezoid is linear, curved or arcuate.

[0018] In an example, a material of the first structural layer includes at least one of zirconium oxide and titanium oxide, and has a first refractive index being greater than or equal to 1.8; and a material of the second structural layer includes at least one of silicon oxide, silicon nitride and fluoropolymer, and has a second refractive index being less than or equal to 1.5.

[0019] In an example, the light-emitting structure layer includes a first light-emitting unit, a second light-emitting unit, and a third light-emitting unit periodically arranged on the substrate.

[0020] An embodiment of present disclosure also provides a display device including the above-mentioned organic light-emitting diode display panel.

[0021] In order to solve the above technical problem, an embodiment of the present disclosure further provides a method for preparing an organic light-emitting diode display panel, including: forming a light-emitting structure layer on the substrate; and forming a light modulation layer on a light exiting path of the light-emitting structure layer, with the light modulation layer being configured to adjust a direction of an emergent light beam.

[0022] In an example, the light modulation layer is formed on a side of the light-emitting structure layer away from the substrate, and the method further includes: forming a protective layer on a side of the light-emitting structure layer away from the substrate which is also a side of the light modulation layer proximate to the substrate; and forming a packaging layer on a side of the light-emitting structure layer away from the substrate.

[0023] In an example, the forming the light modulation layer includes: depositing a first structural thin film, and forming a first structural layer having a plurality of strip protrusions or block protrusions on a surface thereof by a patterning process; and depositing or coating a second structural thin film on the first structural layer, to form a second structural layer filling a recessed space between the plurality of strip protrusions or a recessed space between the plurality of block protrusions.

[0024] In an example, a material of the first structural layer includes at least one of zirconium oxide and titanium oxide, and has a first refractive index greater than or equal to 1.8; and a material of the second structural layer includes at least one of silicon oxide, silicon nitride and fluoropolymer, and has a second refractive index less than or equal to 1.5.

BRIEF DESCRIPTION OF THE DRAWINGS

[0025] The drawings described herein are intended to provide a further understanding of the technical solutions of the present disclosure, and constitute a part of this disclosure. They together with the embodiments of the present disclosure are intended to illustrate the technical solutions of the present disclosure, and do not constitute a limitation of the technical solutions of the present disclosure. The shapes and sizes of the various components in the drawings do not reflect true proportions, but are merely intended to illustrate the present disclosure.

[0026] FIG. 1 is a schematic view showing an OLED display panel according to some embodiments of the present disclosure.

[0027] FIG. 2 is a schematic cross-sectional view showing a structure of a light modulation layer of an OLED display panel according to some embodiments of the present disclosure.

[0028] FIG. 3 is a schematic perspective view showing a structure of a first structural layer of an OLED display panel according to some embodiments of the present disclosure.

[0029] FIG. 4 is a schematic perspective view showing a structure of a second structural layer of an OLED display panel according to some embodiments of the present disclosure.

[0030] FIG. 5 is a schematic cross-sectional view showing a partial structure of a first structural layer of an OLED display panel according to some embodiments of the present disclosure.

[0031] FIG. 6 is a schematic cross-sectional view showing a partial structure of a second structural layer of an OLED display panel according to some embodiments of the present disclosure.

[0032] FIGS. 7 and 8 are schematic views showing the working principle of a light modulation layer of an OLED display panel according to some embodiments of the present disclosure.

[0033] FIG. 9 is a schematic view showing a method for preparing an OLED display panel after a first structural layer pattern is formed according to some embodiments of the present disclosure.

[0034] FIG. 10 is a schematic view showing a method for preparing an OLED display panel after a second structural thin film is formed according to some embodiments of the present disclosure.

[0035] FIG. 11 is a schematic view showing a method for preparing an OLED display panel after a second structural layer pattern is formed according to some embodiments of the present disclosure.

[0036] FIG. 12 is a schematic cross-sectional view showing some extended structures of an OLED display panel according to some embodiments of the present disclosure.

[0037] FIG. 13 is a top view of the structure of FIG. 12.

[0038] FIG. 14 is a schematic view showing a first structural layer of an OLED display panel according to other embodiments of the present disclosure.

[0039] FIG. 15 is a schematic view showing a second structural layer of an OLED display panel according to other embodiments of the present disclosure.

[0040] FIGS. 16a to 16d are schematic cross-sectional views showing a first structural layer of an OLED display panel according to still other embodiments of the present disclosure.

DETAILED DESCRIPTION

[0041] The detailed description of the present disclosure will be further described in detail below with reference to the drawings and examples. The following examples are used to illustrate the disclosure, but are not intended to limit the scope of the disclosure. It should be noted that the embodiments in the disclosure and the features in the embodiments can be arbitrarily combined with each other, as long as they contradict each other.

[0042] According to the study by the inventors of the present disclosure, the reason of the characteristic deviation of viewing angle caused by the microcavity effect is that due to the interference selectivity of each film layer in the light-emitting unit, the color and intensity of the emergent light beam of the film layer will be adjusted according to the thickness of each film layer, and the path (i.e., the optical path) through which the large viewing-angle emergent light beam passes is different from the path through which the

front viewing-angle emergent light beam passes, so that the brightness and chromaticity of the large viewing-angle emergent light beam is low, resulting in a problem of the characteristic deviation of viewing angle. To this end, embodiments of the present disclosure provides an OLED display panel, a method for preparing the same, and a display device including the OLED display panel. According to embodiments of the present disclosure, the direction of the emergent light beam is adjusted, such that the front viewing-angle emergent light beam and the large viewing-angle emergent light beam are redistributed, to balance the brightness and chromaticity between the large viewing angle and the large viewing angle, to effectively solve the problem of characteristic deviation of viewing angle in the related art.

[0043] An OLED display panel according to an embodiment of the present disclosure includes: a substrate, a light-emitting structure layer arranged on the substrate, and a light modulation layer arranged on a light exiting path of the light-emitting structure layer, in which the light modulation layer is configured to adjust the direction of the emergent light beam.

[0044] According to an OLED display panel provided by an embodiment of the present disclosure, the light modulation layer is arranged on the light exiting path of the light-emitting structure layer, in which the light modulation layer is configured to adjust the direction of the emergent light beam to redistribute the front viewing-angle emergent light beam and the large viewing-angle emergent light beam, to effectively solve the problem of characteristic deviation of viewing angle in the related art and improve display quality.

[0045] The technical solutions of the embodiments of the present disclosure will be described in detail below by means of specific embodiments.

[0046] FIG. 1 is a schematic view showing an OLED display panel according to some embodiments of the present disclosure. As shown in FIG. 1, the OLED display panel of this embodiment includes: a substrate 10; a light-emitting structure layer 20 arranged on the substrate 10, in which the light-emitting structure layer 20 includes a first light-emitting unit 21, a second light-emitting unit 22, and a third light-emitting unit 23 periodically arranged, and the first light-emitting unit 21, the second light-emitting unit 22 and the third light-emitting unit 23 are capable of emitting light under the driving of the substrate 10; a protective layer 30 arranged on the light-emitting structure layer 20; a light modulation layer 40 arranged on the protective layer 30, in which the light modulation layer 40 is configured to adjust the directions of emergent light beams from the first light-emitting unit 21, the second light-emitting unit 22, and the third light-emitting unit 23; and a packaging layer 50 arranged on a side of the light modulation layer 40 away from the substrate.

[0047] In this embodiment, the display panel includes a plurality of pixel units arranged in a matrix, and each of the plurality of pixel units includes at least three sub-pixels. In the structure shown in FIG. 1, one pixel unit includes three sub-pixels, that is, a first light-emitting unit 21, a second light-emitting unit 22 and a third light-emitting unit 23 in the light-emitting structure layer 20. These three light-emitting units respectively are a red light-emitting unit, a green light-emitting unit and a blue light-emitting unit, to form a red sub-pixel R, a green sub-pixel G, and a blue sub-pixel B, respectively. Of course, the solution of the embodiment of the present disclosure is also applicable to a case where one

pixel unit includes four sub-pixels (i.e. a red sub-pixel R, a green sub-pixel G, a blue sub-pixel B, and a white sub-pixel W). In this embodiment, the substrate 10 includes a driving circuit, and each of the light-emitting units includes a first electrode, an organic electroluminescence layer and a second electrode, in which the organic electroluminescent layer is arranged between the first electrode and the second electrode, includes an organic light-emitting layer, and is capable of emitting light of a set color under the driving by an electric field between the first electrode and the second electrode. One electrode of the first electrode and the second electrode is a reflective electrode, and the other electrode is a transmissive electrode or a transflective electrode. In this embodiment, the protective layer 30 is used to protect each of the light-emitting units.

[0048] In this embodiment, the light modulation layer 40 has a characteristic of totally reflecting and refracting the emergent light beam, so that a part of the front viewing-angle emergent light beam from the light-emitting structure layer 20 is totally reflected and changed into a large viewing-angle emergent light beam, and a part of the large viewing-angle emergent light beam from the light-emitting structure layer 20 is refracted and changed into a front viewing-angle emergent light beam, so as to adjust the direction of the emergent light beam from the light-emitting unit, to redistribute the front viewing-angle emergent light beam and the large viewing-angle emergent light beam, so as to balance the brightness and chromaticity of the front viewing-angle emergent light beam and the large viewing-angle emergent light beam, and eliminate the characteristic deviation of viewing angle.

[0049] FIG. 2 is a schematic cross-sectional view showing a structure of a light modulation layer of an OLED display panel according to some embodiments of the present disclosure. As shown in FIG. 2, the light modulation layer of this embodiment includes a first structural layer 41 and a second structural layer 42 which are stacked, in which the first structural layer 41 has a first refractive index n_1 and the second structural layer 42 has a second refractive index n_2 , with $n_1 > n_2$.

[0050] FIG. 3 is a schematic perspective view showing a structure of a first structural layer of an OLED display panel according to some embodiments of the present disclosure. FIG. 4 is a schematic perspective view showing a structure of a second structural layer of an OLED display panel according to some embodiments of the present disclosure. As shown in FIG. 3, the first structural layer 41 is a plate structure, on the surface (upper surface) of which facing the second structural layer 42 a plurality of strip projections 411 is sequentially arranged. As shown in FIG. 4, the second structural layer 42 is a plate structure, on the surface (lower surface) of which facing the second structural layer 41 a plurality of strip grooves 421 is sequentially arranged. In the structure shown in FIGS. 3 and 4, the strip protrusions 411 and the strip grooves 421 are same in the cross-sectional shape in a plane perpendicular to the substrate and parallel to the longitudinal direction of the substrate, are same in their arrangement, the arrangement pitch and the like parameters, so that when the second structural layer 42 is arranged on the first structural layer 41, the plurality of strip grooves 421 on the second structural layer 42 is closely attached or buckled with the plurality of strip protrusions 411 on the first structural layer 41, thereby forming a light modulation structure in which a material having a high refractive index

and a material having a low refractive index are arranged in turn in the plane direction of the substrate and in a direction perpendicular to the plane direction of the substrate. In other words, a plurality of recessed spaces is formed between the plurality of strip protrusions **411** formed on the first structural layer **41**, and the second structural layer **42** fills these recessed spaces and forms a flattened surface, to form the first structural layer **41** and the second structural layer **42** in a stacked way.

[0051] FIG. 5 is a schematic cross-sectional view showing a partial structure of a first structural layer of an OLED display panel according to some embodiments of the present disclosure. FIG. 6 is a schematic cross-sectional view showing a partial structure of a second structural layer of an OLED display panel according to some embodiments of the present disclosure, in which the cross section is a plane perpendicular to the substrate and parallel to the length direction of the substrate. As shown in FIG. 5, the thickness of the first structural layer is H, and the strip protrusions **411** provided thereon has a shape of an isosceles trapezoid in the cross section, of which the lower side is L, the upper side is B, the height is h, the angle (slope angle) between the lateral side and the lower side is θ , and the pitch between adjacent strip protrusions **411** is D. As shown in FIG. 6, the thickness of the second structural layer is H, and the strip grooves **421** provided thereon has a shape of an isosceles trapezoid in the cross section, of which the lower side is L, the upper side is B, the height is h, the slope angle of the lateral side is θ , and the pitch between adjacent strip protrusions **411** is D. That is, the cross section of the strip protrusion **411** and the cross section of the strip groove **421** are the same in shape and geometrical parameters. In one example, the height h of the strip protrusion is equal to the thickness H of the first structural layer, and the height h of the strip groove is equal to the thickness H of the second structural layer, that is, the light modulation layer is formed by sequentially jointing a strip of a high refractive index material and a strip of a low refractive index material.

[0052] FIGS. 7 and 8 are schematic views showing the working principle of a light modulation layer of an OLED display panel according to some embodiments of the present disclosure, in which the height h of the strip protrusion (groove) is equal to the thickness H of the first (second) structure layer. As shown in FIG. 7, after the front viewing-angle emergent light beam emitted by the light-emitting unit is incident into the first structural layer **41**, the light **S1** incident on the upper side of the trapezoid directly exits and is still the front viewing-angle emergent light beam. The light **S2** incident on the lateral side of the trapezoid is totally reflected, and the total reflected light is reflected back into the first structural layer **41**. When the thickness H of the second structural layer is greater than the height h of the cross-section trapezoid, the total reflected light reflected back into the first structural layer **41** is incident into the second structural layer **42** and exits from the second structural layer **42**, to form a large viewing-angle emergent light beam. As shown in FIG. 8, after the large viewing-angle emergent light beam emitted by the light-emitting unit is incident into the first structural layer **41**, the light **X1** incident on the lateral side of trapezoid is refracted, and the refracted light is emitted through the second structural layer **42**, to form a front viewing-angle emergent light beam. In this embodiment, a viewing angle is an angle between a normal direction of a display plane and a line of sight, the

front viewing-angle emergent light beam is an emergent light beam having a viewing-angle in the range of 0° to 15° , and the large viewing-angle emergent light beam is an emergent light beam having a viewing-angle greater than 40° .

[0053] According to optical principles, when light is incident from a large refractive index material into a small refractive index material, if the incident angle α of the incident light exceeds the critical angle α_0 , the incident light will be totally reflected at the material interface; and if the incident angle α of the incident light does not exceed the critical angle α_0 , a refraction will occur. The relationship between the critical angle α_0 and the refractive index is: $\sin \alpha_0 = n_2/n_1$. In this embodiment, the first refractive index **n1** of the first structural layer **41** is set to be greater than or equal to 1.8, the second refractive index **n2** of the second structural layer **42** is set to be less than or equal to 1.5, and the slope angle θ of the lateral side of the trapezoid is set to be $55^\circ \leq \theta \leq 90^\circ$. Thus, it is possible to totally reflect the front viewing-angle emergent light beam incident on the lateral side of the trapezoid, and refract the large viewing-angle emergent light beam incident on the lateral side of the trapezoid. In one example, the slope angle θ of the lateral side of trapezoid is: $65^\circ \leq \theta \leq 80^\circ$. In an example, during the implementation, the material of the first structural layer may include at least one of or a combination of zirconium oxide, titanium oxide, high refractive index resin material, etc., and the material of the second structural layer may be at least one of or a combination of silicon oxide, silicon nitride, fluoropolymer, etc.

[0054] In this embodiment, a part of the front viewing-angle emergent light beam is changed into a large viewing-angle emergent light beam by total reflection, which increases the large viewing-angle emergent light beam, reduces the front viewing-angle emergent light beam, and is capable of effectively eliminating the difference between the brightness of the front viewing angle and the brightness of the large viewing angle. Given that the microcavity structure is selective for wavelength, the front viewing-angle emergent light beam and the large viewing-angle emergent light beam have different wavelength ranges. In this embodiment, a part of the front viewing-angle emergent light beam is changed into a large viewing-angle emergent light beam by total reflection, meanwhile a part of the large viewing-angle emergent light beam is changed into the front viewing-angle emergent light beam by refraction, which not only increases the wavelength range of the large viewing-angle emergent light beam, but also increases the wavelength range of the front viewing-angle emergent light beam, thereby effectively eliminating the difference between the chromaticity of the front viewing angle and the chromaticity of the large viewing angle. In other words, in this embodiment, the brightness of the large viewing angle is compensated by the brightness of the front viewing angle, and the difference in chromaticity is eliminated by the complementary of the chromaticity of the front viewing angle and the chromaticity of the large viewing angle. In view of this, in this embodiment, the light modulation structure is formed by arranging the high refractive index material and the low refractive index material in turn, and the front viewing-angle emergent light beam and the large viewing-angle emergent light beam are redistributed by adjusting the direction of the emergent light beam, thereby realizing the balance of the brightness and chromaticity between the front viewing angle and the

large viewing angle, effectively solves the problem of the characteristic deviation of viewing angle in the related art, and improves display quality.

[0055] The method for preparing the OLED display panel according to some embodiments of the present disclosure is described below. The “patterning process” in this embodiment includes processes such as depositing a film layer, coating a photoresist, exposing a mask, development, etching, stripping a photoresist, etc., and is a mature preparation process in the related art. The deposition may be carried out by a known process such as sputtering, chemical vapor deposition, etc. The coating may be carried out by a known coating process. The etching may be carried out by a known method, which is not specifically limited herein.

[0056] (1) First, a pattern of the substrate **10** is prepared. The substrate **10** includes a plurality of gate lines and a plurality of data lines. The plurality of gate lines and the plurality of data lines perpendicularly intersect to form a plurality of matrix-arranged pixel units, in which each of the pixel units includes at least three or four sub-pixels, and each of the sub-pixels includes a thin film transistor (TFT). Generally, one pixel unit includes three sub-pixels: a red sub-pixel R, a green sub-pixel G, and a blue sub-pixel B. One pixel unit may also include four sub-pixels: a red sub-pixel R, a green sub-pixel G, a blue sub-pixel B and a white sub-pixel W. For example, the preparation process may include: cleaning a base; preparing an active layer on the base by a patterning process; forming a first insulating layer covering the active layer; forming a gate line and a gate electrode on the first insulating layer; forming a second insulating layer covering the gate line and the gate electrode; forming a data line, a source electrode and a drain electrode on the second insulating layer; and forming an overcoat covering the data line, the source electrode and the drain electrode. The thin film transistor may be of a bottom gate structure or a top gate structure; and may be an amorphous silicon (a-Si) thin film transistor or a low temperature polysilicon (LTPS) thin film transistor or an oxide thin film transistor, which is not specifically limited in this embodiment. In one example, during the implementation, the base may be made of glass, quartz, polyolefin resin, polyethylene naphthalate-based resin, polyimide-based resin, polyphthalic plastic, phenol resin, or other high light transmissive materials; or a surface-treated polymer soft film, etc. Subsequently, a pattern of the light-emitting structure layer **20** is formed on the base on which the pattern of the substrate **10** is formed. For example, a first electrode is formed on a base on which the above-mentioned pattern is formed, and the first electrode is connected to a drain electrode of the thin film transistor through a via hole. Then, a pixel definition layer is formed which is arranged to define a light-emitting region in each sub-pixel, in which the light-emitting region exposes the first electrode. Subsequently, an organic electroluminescent layer is formed in the light-emitting region, and then a second electrode is formed. As for the top emitting OLED of the embodiment, the first electrode is a reflective electrode, and the second electrode is a transmissive electrode or a transreflective electrode, in which a material having a lower work function, such as magnesium Mg, silver Ag, aluminum Al or alloy, is used. The organic electroluminescent layer mainly includes an organic light-emitting layer (EML). In one example, the organic electroluminescent layer includes, in addition to the organic light-emitting layer, an electron transport layer (ETL) and a

hole transport layer (HTL); and further includes an electron injection layer (EIL), a hole injection layer (HIL), a light extraction layer, etc., in order to improve the efficiency of the injection of electrons and holes into the organic light-emitting layer. The material of the electron transport layer is, for example, an organic compound having a higher excited state energy level or a derivative thereof. The material of the organic light-emitting layer may be an organic small molecule or polymer material. The material of the hole transport layer may be an organic compound having a higher hole mobility and a lower free potential or a derivative thereof, e.g., aromatic amine, carbazole, etc.

[0057] (2) A light modulation layer pattern is formed on the base on which the above-mentioned pattern is formed. The forming the light modulation layer pattern includes: coating a protective layer **30** on the base on which the above-mentioned pattern is formed; depositing the first structural thin film; coating a photoresist on the first structural thin film; exposing and developing the photoresist using a monotone mask, so that an unexposed region is formed at the position of the strip protrusion and the photoresist is reserved, and a completely exposed region is formed at other positions and the photoresist is removed; and the first structural thin film of the completely exposed region is removed by an etching process, to form the first structural layer **41** pattern having a strip projection **411** on its surface, as shown in FIG. 9. The morphology of the lateral side of the trapezoid can be adjusted by selecting an etching gas and controlling the etching rate, etc., and the related process is well known in the art and will not be described herein. Subsequently, a second structural thin film is deposited on the base on which the pattern of the first structural layer **41** is formed, such that the second structural thin film completely fills the space in which the first structural layer **41** is etched, as shown in FIG. 10. Subsequently, the protrusion on the surface of the second structural thin film is removed by a grinding process to planarize the surface thereof, to form a pattern of the second structural layer **42**. That is, the second structural layer **42** having a plurality of strip grooves arranged in sequence on its lower surface is snapped onto the upper surface of the first structural layer **41**, thereby finally forming a light modulation layer pattern, as shown in FIG. 11. In one example, during the implementation, when the second structural thin film is made of an organic material, the second structural layer pattern with a flattened surface may be directly formed by a coating method, and the second structural layer completely fills the space between the strip projection of the first structural layers.

[0058] (3) Finally, a pattern of the packaging layer **50** is formed on the base on which the above-mentioned pattern is formed, and the packaging layer **50** is located on the side of the light modulation layer **40** away from the substrate **10** and may be made of an organic or inorganic material, such as tetrafluoroethylene TFE. The structure of the formed packaging layer pattern and the preparation process are the same as those in the related art, and will not be described herein.

[0059] As can be seen from the introduction of the above technical solution and the preparation process thereof, in the OLED display panel provided in this embodiment, a light modulation layer is arranged on the light exiting path of the light-emitting structure layer, in which the light modulation layer has the characteristics of refracting and totally reflecting the emergent light beam, so that a part of the front

viewing-angle emergent light beam is changed into a large viewing-angle emergent light beam by total reflection, and a part of the large viewing-angle emergent light beam is changed into a front viewing-angle emergent light beam by refraction, so that the large viewing-angle emergent light beam and the front viewing-angle emergent light beam are redistributed by adjusting the direction of the emergent light beam, thereby achieving the balance of brightness and chromaticity between the front viewing angle and the large viewing angle, effectively solving the problem of the characteristic deviation of viewing angle in the related art, eliminating the characteristic deviation of viewing angle, and improving the display quality. In addition, the preparation of the light modulation layer in the embodiment can be realized by using the mature preparation equipment in the related art. The changing to the process of the related technology is small, the preparation process is simple, the production cost is low, the production precision is high, and the application prospect is promising.

[0060] Although this embodiment has been described with a top emitting OLED, the solution of this embodiment is also applicable to a bottom emitting OLED or a double-sided emitting OLED. At the same time, the structure of the OLED display panel may have a lot of variants. For example, when the light modulation layer is made of an inorganic material, the light modulation layer can be directly arranged on the light-emitting structure layer, such that the light modulation layer can simultaneously serve as a protective layer of the light-emitting structure layer. There is no need to set a protective layer in this case. For another example, a structure, in which an packaging layer is arranged on the light-emitting structure layer and a light modulation layer is arranged on the packaging layer, may be used. For yet another example, a structure, in which the light modulation layer is arranged in the packaging layer or the light modulation layer and the packaging layer are arranged in an integrated structure, may be used. For yet another example, when the OLED display panel includes a cover plate, the light-emitting structure layer may be arranged on the substrate to form a light-emitting substrate, the light modulation layer may be arranged on the cover plate to form a light processing substrate, and then the light-emitting substrate and the light processing substrate may form an OLED display panel through a cell alignment. When the light modulation layer is arranged on the cover plate, the influence of the process for preparing the light modulation layer on the light-emitting structure layer can be omitted, and the materials and the process parameters can be widely selected. In addition, the light modulation layer of this embodiment may be of a stacked structure including a plurality of modulation layers sequentially stacked, each of which includes a first structural layer and a second structural layer.

[0061] In an example, during implementation, the arrangement of the strip protrusions (grooves), and the lower side L, the upper side B, the height h and the pitch D of the trapezoid can be designed as required, and are not specifically limited herein. Generally, the strip protrusions (grooves) may be arranged in a pixel row or a pixel column, and the positions correspond to a sub-pixel row or a sub-pixel column of the substrate. Although this embodiment has been described by taking the plane shape of the strip protrusions (grooves) being a long strip as an example, according to the technical concept of this embodiment, the plane shape of the strip protrusions (grooves) of this

embodiment can also be other shapes, such as curved lines or fold lines. In an example, during implementation, parameters such as the lower side L, the upper side B and the height h of the trapezoid may be set according to the size of the light-emitting unit. Generally, the position of the trapezoid corresponds to the position of the light-emitting unit. As can be seen from the technical concept of the embodiment, the structure of the light modulation layer of this embodiment can be expanded in various ways. For example, in the first (second) structural layer, the pitch D between adjacent strip protrusions (grooves) may be set to D=0. For another example, the height h of the strip projections (grooves) may be set to be equal to the thickness H of the first (second) structural layer. For another example, the trapezoid can be a non-isosceles trapezoid, in which a slope angle of one lateral side is greater than the slope angle of the other lateral side, or the lower side and the upper side of the trapezoid can also be designed as non-parallel shape as required. The brightness and chromaticity of certain viewing angles can be compensated by changing the slope angle as well as the bottom and top sides. FIG. 12 is a schematic cross-sectional view showing some extended structures of an OLED display panel according to some embodiments of the present disclosure. FIG. 13 is a top view of the structure of FIG. 12. As shown in FIGS. 12 and 13, the light-emitting structure layer 20 is arranged on the substrate 10, and the light modulation layer 400 is arranged on the light-emitting structure layer 20, in which the height of the strip protrusions on the first structural layer 41 is equal to the thickness of the first structural layer 41, the height of the strip grooves on the second structural layer 42 is equal to the thickness of the second structural layer 42, and the pitch between adjacent strip protrusions is zero.

[0062] The main structure of the OLED display panel provided by other embodiments includes: a substrate 10, a light-emitting structure layer 20 arranged on the substrate 10, a protective layer 30 arranged on the light-emitting structure layer 20, a light modulation layer 40 arranged on the protective layer 30, and an packaging layer 50 located on a side of the light modulation layer 40 away from the substrate, in which the light modulation layer 40 includes a first structural layer 41 and a second structural layer 42 which are stacked. Different from the above-mentioned embodiment, a plurality of block protrusion is provided on the first structural layer 41 of this embodiment, and a plurality of block groove is provided on the second structural layer 42.

[0063] FIG. 14 is a schematic view showing a first structural layer of an OLED display panel according to other embodiments of the present disclosure. FIG. 15 is a schematic view showing a second structural layer of an OLED display panel according to other embodiments of the present disclosure. As shown in FIG. 14, a plurality of block protrusions 412 is provided on the surface of the first structural layer 41 facing the second structural layer 42, in which the plurality of block protrusions 412 is regularly arranged in a matrix manner. As shown in FIG. 15, a plurality of block grooves 422 is provided on the surface of the second structural layer 42 facing the first structural layer 41, in which the plurality of block grooves 422 is regularly arranged in a matrix manner. The block protrusions 412 and the block grooves 422 are same in the cross-sectional shape in a plane perpendicular to the substrate and parallel to the longitudinal direction of the substrate, are same in their

arrangement, the arrangement pitch and the like parameters, so that when the second structural layer **42** is arranged on the first structural layer **41**, the plurality of block grooves **422** on the second structural layer **42** may be closely attached or buckled on the plurality of block protrusions **412** on the first structural layer **41**, such that each of the high refractive index material of the block protrusions **412** is surrounded by the low refractive index material of the second structural layer **42**, thereby forming a light modulation structure in which a high refractive index material and a low refractive index material are arranged in turn in the plane direction of the substrate and in a direction perpendicular to the plane direction of the substrate.

[0064] In this embodiment, the refractive indices and materials of the first structural layer and the second structural layer, the cross-sectional shape in a plane perpendicular to the substrate and parallel to the longitudinal direction of the substrate, geometric parameters, the working principle of total reflection and refraction of light, the preparation process of the first structural layer and the second structural layer, and the expansion manner of the structure, etc. are all the same as those of the above-mentioned embodiments, so that this embodiment also achieves the technical effects of redistributing the front viewing-angle emergent light beam and the large viewing-angle emergent light beam by adjusting the direction of the emergent light beam, of effectively solving the problem of the characteristic deviation of viewing angle in the related art, and of improving display quality. In addition, since this embodiment forms a two-dimensional light modulation structure, the characteristic deviation of viewing angle can be eliminated in two dimensions.

[0065] In this embodiment, the cross-sectional shape of the block projections (grooves) is a trapezoid in a plane perpendicular to the substrate **10** and parallel to the longitudinal direction of the substrate **10**, and the cross-sectional shape of the block projections (grooves) may be a rectangle (including a square) in the plane parallel to the substrate **10**, that is, each of the block protrusions (grooves) may be a prismatic shape, or the cross-sectional shape of the block projections (grooves) may be an elliptical shape (including a circular shape) in the plane parallel to the substrate **10**, that is, each of the block protrusions (grooves) is a truncated cone shape, or the cross-sectional shape of the block projections (grooves) in the plane parallel to the substrate **10** may also be a regular shape such as a polygon. The above shapes can all achieve the technical effects of the present disclosure.

[0066] The OLED display panel provided by some other embodiments is an extension of the above-mentioned embodiment, and the main structure of the OLED display panel is the same as that of the above-mentioned embodiments. Different from the above-mentioned embodiment, in the plane perpendicular to the substrate **10** and parallel to the longitudinal direction of the substrate **10**, the cross-sectional shape of the strip projections (grooves) or the block projections (grooves) of this embodiment is an extended shape of the trapezoid, which is called a trapezoid-like shape.

[0067] FIGS. 16a to 16d are schematic cross-sectional views showing a first structural layer of an OLED display panel according to still other embodiments of the present disclosure. In a plane perpendicular to the substrate and parallel to the length direction of the substrate, the cross-sectional shape of the strip (block) protrusions of this embodiment is a trapezoid-like shape, in which two lateral

sides of the trapezoid-like shape are of a fold line shape, such that the lateral sides of the trapezoid-like shape have at least two slope angles θ_1 and θ_2 . In one embodiment, $\theta_1 > \theta_2$, i.e., the fold line has a shape protruding to the outside of the lateral side, as shown in FIG. 16a. In another embodiment, $\theta_1 < \theta_2$, that is, the fold line has a shape recessing toward the inside of the lateral side, as shown in FIG. 16b.

[0068] In this embodiment, the cross-sectional shape of the strip (block) protrusions is designed into a trapezoid-like shape, so that not only the technical effects of the above-mentioned embodiments can be achieved, but also the redistribution of the front viewing-angle emergent light beam and the large viewing-angle emergent light beam can be further refined, so that a part of the front viewing-angle emergent light beam incident on the lateral side of the fold line shape is totally reflected, and other part of the front viewing-angle emergent light beam incident on the lateral side of the fold line shape is refracted. For the same reason, it is also possible to control the refraction direction of the large viewing-angle emergent light beam incident onto the lateral side of fold-line shape.

[0069] On the basis of the technical concept of the embodiment, the trapezoid-like shape can have many variations. For example, the two lateral sides of the trapezoid-like shape may be of an arc shape, in which the arc shape may protrude toward the outside of the lateral side, or may be recess toward the inside of the lateral side. For another example, as a special evolution of the lateral side being of an arc shape, the upper side of the trapezoid-like shape is continuously reduced, and the trapezoid-like shape can be evolved into a semicircular or semi-elliptical shape, as shown by FIG. 16c. For another example, as a special evolution of the trapezoid-like shape, the cross-sectional shape can evolve to approximate a rectangle or approximate a triangle, as shown in FIG. 16d. Of course, when the cross-sectional shape is approximately triangular, all of the front viewing-angle emergent light beam emitted from the light-emitting unit is totally reflected; and when the cross-sectional shape is approximately rectangular, all of the large viewing-angle emergent light beam emitted from the light-emitting unit is refracted.

[0070] Based on the technical concept of the above-mentioned embodiment, a method for preparing an OLED display panel is further provided in an embodiment of the present disclosure. The method for preparing the OLED display panel of this embodiment includes:

[0071] S1: forming a light-emitting structure layer on the substrate; and

[0072] S2: forming a light modulation layer on a light exiting path of the light-emitting structure layer, with the light modulation layer being configured to adjust a direction of an emergent light beam.

[0073] Step S2 may include forming the light modulation layer on a side of the light-emitting structure layer away from the substrate; or, the method further includes: forming a protective layer on a side of the light-emitting structure layer away from the substrate which is also a side of the light modulation layer proximate to the substrate; or forming a protective layer on a side of the light-emitting structure layer away from the substrate which is also a side of the light modulation layer proximate to the substrate; or forming an packaging layer on a side of the light-emitting structure layer away from the substrate, and the light modulation layer

is formed in the packaging layer; or forming a cover plate on a side of the light modulation layer away from the substrate. [0074] Specifically, the forming the light modulation layer includes: depositing a first structural thin film, and forming a first structural layer having a plurality of strip protrusions or block protrusions on a surface thereof by a patterning process; and depositing or coating a second structural thin film on the first structural layer, to form a second structural layer filling a recessed space between the plurality of strip protrusions or a recessed space between the plurality of block protrusions.

[0075] A material of the first structural layer may include at least one of zirconium oxide and titanium oxide, and may have a first refractive index greater than or equal to 1.8; and a material of the second structural layer may include at least one of silicon oxide, silicon nitride and fluoropolymer, and may have a second refractive index less than or equal to 1.5.

[0076] The cross-sectional shape of the strip protrusion or the block protrusion may be trapezoidal in a plane perpendicular to the substrate and parallel to the length direction of the substrate, in which an angle θ between the lateral side and the lower side of the trapezoid is greater than or equal to 55° and less than or equal to 90° , a height of the trapezoid is equal to the thickness of the first structural layer or the second structural layer, and a pitch between the strip protrusions or the block protrusions is zero.

[0077] The lateral side of the trapezoid may be linear, curved or arcuate.

[0078] The step S1 may include forming a first light-emitting unit, a second light-emitting unit, and a third light-emitting unit periodically arranged on the substrate.

[0079] The structure, material and related parameters of the light-emitting structure layer and the light modulation layer and the detailed preparation process thereof have been described in detail in the above-mentioned embodiments, and are not described herein again.

[0080] In the method for preparing an OLED display panel provided by this embodiment, a light modulation layer is arranged on the light exiting path of the light-emitting structure layer, in which the light modulation layer has the characteristics of refracting and totally reflecting the emergent light beam, so that a part of the front viewing-angle emergent light beam is changed into a large viewing-angle emergent light beam by total reflection, and a part of the large viewing-angle emergent light beam is changed into a front viewing-angle emergent light beam by refraction, so that the large viewing-angle emergent light beam and the front viewing-angle emergent light beam are redistributed by adjusting the direction of the emergent light beam, thereby achieving the balance of brightness and chromaticity between the front viewing angle and the large viewing angle, effectively solving the problem of the characteristic deviation of viewing angle in the related art, eliminating the characteristic deviation of viewing angle, and improving the display quality. The method for preparing the OLED display panel of this embodiment can be realized by using the mature preparation equipment in the related art. The changing to the process of the related technology is small, the preparation process is simple, the production cost is low, the production precision is high, and the application prospect is promising.

[0081] Based on the technical concept of the above-mentioned embodiments, a display device including the OLED display panel provided in the above-mentioned

embodiment is also provided in an embodiment of the present disclosure. The OLED display device may be any one of a display panel, a mobile phone, a tablet computer, a television, a notebook computer, a digital photo frame, a navigator, or any product or component having a display function.

[0082] In the description of the present invention, it should be noted that the terms "middle", "up", "down", "front", "front", "vertical", "horizontal", "top", "bottom", "inside", "outside", etc. indicating the orientation or spatial relationship is based on the orientation or spatial relationship shown in the drawings, and are merely for the convenience of describing the present invention and the simplification of the description, rather than indicating or implying that the referred device or element must have a particular orientation, or be constructed and operated in a particular orientation. Thus, those terms should not be construed as a limitation on the present invention.

[0083] In the description of the embodiment of the present disclosure, it should be noted that, unless expressly stated or limited otherwise, the terms "mount", "connect" or "join" shall be interpreted broadly, and may be, for example, fixed connection, removable connection, or integral connection; may be a mechanical connection, may also be an electrical connection; may be direct connection, or may be indirect connection through an intermediary medium, and may be the internal communication of two components. Those skilled in the art would understand the specific meanings of the above terms in the present disclosure according to specific circumstances.

[0084] It should be understood that the implementation of any of the products or methods of the present disclosure does not necessarily achieve all of the above-mentioned advantages at the same time. The various features and advantages of the present disclosure are illustrated in the embodiments in the specification, and a part of the features and advantages will be apparent from the embodiments in the specification or be learned by implementing embodiments of the disclosure. The objectives and other advantages of the present disclosure can be realized and obtained by the structure particularly set forth in specification, drawings, and claims.

[0085] The embodiments disclosed in the present disclosure are as described above, but they are merely used to facilitate the understanding of the embodiments of the present disclosure, and are not intended to limit the embodiments of the present disclosure. Any modification and variation in the form and details of the embodiments may be made by a person skilled in the art without departing from the spirit and scope of the embodiments of the present disclosure. The scope of patent protection is still subject to the scope defined by the appended claims.

What is claimed is:

1. An organic light-emitting diode (OLED) display panel, comprising a substrate, a light-emitting structure layer arranged on the substrate, and a light modulation layer arranged on a light exiting path of the light-emitting structure layer and configured to adjust a direction of an emergent light beam.

2. The OLED display panel of claim 1, wherein the light modulation layer is configured to totally reflect a part of a front viewing-angle emergent light beam from the light-emitting structure layer to change it into a large viewing-angle emergent light beam, and to refract a part of a large viewing-angle emergent light beam from the light-emitting

structure layer to change it into a front viewing-angle emergent light beam, so as to redistribute the front viewing-angle emergent light beam and the large viewing-angle emergent light beam,

a viewing angle is an angle between a normal direction of a display plane and a line of sight, the front viewing-angle emergent light beam is an emergent light beam having a viewing-angle in the range of 0° to 15° , and the large viewing-angle emergent light beam is an emergent light beam having a viewing-angle greater than 40° .

3. The OLED display panel of claim 1, wherein the light modulation layer is located on a side of the light-emitting structure layer away from the substrate.

4. The OLED display panel of claim 3, further comprising:

a protective layer arranged on a side of the light-emitting structure layer away from the substrate which is also a side of the light modulation layer proximate to the substrate; and

a packaging layer arranged on a side of the light-emitting structure layer away from the substrate.

5. The OLED display panel of claim 3, wherein the light modulation layer comprises a first structural layer and a second structural layer which are stacked, with the first structural layer having a first refractive index, and the second structural layer having a second refractive index less than the first refractive index.

6. The OLED display panel of claim 5, wherein a plurality of strip protrusions is provided on a surface of the first structural layer facing the second structural layer; and a plurality of strip grooves is provided on a surface of the second structural layer facing the first structural layer, with the plurality of strip grooves on the second structural layer being attached to the plurality of strip protrusions on the first structural layer, and with each pair of the plurality of strip protrusions and the plurality of strip grooves having the same shape of trapezoid in a cross section perpendicular to the substrate and parallel to a length direction of the substrate.

7. The OLED display panel of claim 5, wherein a plurality of block protrusions is provided on a surface of the first structural layer facing the second structural layer; and a plurality of block grooves is provided on a surface of the second structural layer facing the first structural layer, with the plurality of block grooves on the second structural layer being attached to the plurality of block protrusions on the first structural layer, and with each pair of the plurality of block protrusions and the plurality of block grooves having the same shape of trapezoid in a cross section perpendicular to the substrate and parallel to a length direction of the substrate.

8. The OLED display panel of claim 6, wherein an angle θ between a lateral side and a lower side of the trapezoid is greater than or equal to 55° and less than or equal to 90° .

9. The OLED display panel of claim 6, wherein a height of the trapezoid is equal to a thickness of the first structural layer or the second structural layer, and a pitch between the plurality of strip protrusions is zero.

10. The OLED display panel of claim 6, wherein a lateral side of the trapezoid is linear, curved or arcuate.

11. The OLED display panel of claim 7, wherein an angle θ between a lateral side and a lower side of the trapezoid is greater than or equal to 55° and less than or equal to 90° .

12. The OLED display panel of claim 7, wherein a height of the trapezoid is equal to a thickness of the first structural layer or the second structural layer, and a pitch between the plurality of block protrusions is zero.

13. The OLED display panel of claim 7, wherein a lateral side of the trapezoid is linear, curved or arcuate.

14. The OLED display panel of claim 5, wherein a material of the first structural layer comprises at least one of zirconium oxide and titanium oxide, with the first refractive index being greater than or equal to 1.8; and a material of the second structural layer comprises at least one of silicon oxide, silicon nitride and fluoropolymer, with the second refractive index being less than or equal to 1.5.

15. The OLED display panel of claim 1, wherein the light-emitting structure layer comprises a first light-emitting unit, a second light-emitting unit, and a third light-emitting unit periodically arranged on the substrate.

16. A display device comprising the OLED display panel of claim 1.

17. A method for preparing an OLED display panel, comprising:

forming a light-emitting structure layer on the substrate; and

forming a light modulation layer on a light exiting path of the light-emitting structure layer, with the light modulation layer being configured to adjust a direction of an emergent light beam.

18. The method of claim 17, wherein the light modulation layer is formed on a side of the light-emitting structure layer away from the substrate, and the method further comprises:

forming a protective layer on a side of the light-emitting structure layer away from the substrate which is also a side of the light modulation layer proximate to the substrate; and

forming a packaging layer on a side of the light-emitting structure layer away from the substrate.

19. The method of claim 17, wherein the forming the light modulation layer comprises:

depositing a first structural thin film, and forming a first structural layer having a plurality of strip protrusions or block protrusions on a surface thereof by a patterning process; and

depositing or coating a second structural thin film on the first structural layer, to form a second structural layer filling a recessed space between the plurality of strip protrusions or a recessed space between the plurality of block protrusions.

20. The method of claim 17, wherein a material of the first structural layer comprises at least one of zirconium oxide and titanium oxide, and has a first refractive index greater than or equal to 1.8; and a material of the second structural layer comprises at least one of silicon oxide, silicon nitride and fluoropolymer, and has a second refractive index less than or equal to 1.5.

专利名称(译)	有机发光二极管显示面板，其制备方法和显示装置		
公开(公告)号	US20200185652A1	公开(公告)日	2020-06-11
申请号	US16/516894	申请日	2019-07-19
[标]申请(专利权)人(译)	京东方科技股份有限公司		
申请(专利权)人(译)	京东方科技股份有限公司.		
当前申请(专利权)人(译)	京东方科技股份有限公司.		
[标]发明人	SUN HAIYAN		
发明人	SUN, HAIYAN		
IPC分类号	H01L51/52 H01L51/56		
CPC分类号	H01L51/5253 H01L51/5275 H01L27/3213 H01L51/5271 H01L51/56 H01L51/5262		
优先权	201811503645.1 2018-12-10 CN		
外部链接	Espacenet USPTO		

摘要(译)

本公开提供了一种有机发光二极管显示面板，其制备方法以及显示装置。有机发光二极管显示面板包括基板，布置在基板上的发光结构层以及布置在发光结构层的光出射路径上并被配置为调节出射方向的光调制层。光束。

